

A New Reagent for Direct Difluoromethylation

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Supporting Information

ABSTRACT: Molecular scaffolds containing alkylfluorine substituents are desired in many areas of chemical research from materials to pharmaceuticals. Herein, we report the invention of a new reagent (Zn(SO₂CF₂H)₂, DFMS) for the innate difluoromethylation of organic substrates via a radical process. This mild, operationally simple, chemoselective, and scalable difluoromethylation method is compatible with a range of nitrogen-containing heteroarene substrates of varying complexity as well as select classes of conjugated π -systems and thiols. Regiochemical comparisons suggest that the CF₂H radical generated from the new reagent possesses nucleophilic character.

he difluoromethyl group (CF₂H) is an intriguing structural motif that has great potential in the areas of pharmaceuticals, agrochemicals, and materials. 1-5 In the area of medicinal chemistry, the CF₂H unit is of special interest for its use in isostere-based drug design. lipophilic hydrogen bond donor, CF₂H substitution offers an alternative to more traditional hydrogen bond donors while improving membrane permeability. For example, the difluoromethyl group has been utilized as a thiol mimic in the context of HCV NS3 protease inhibitors, successfully mimicking the cysteine CH₂SH P1 element in the parent compounds. It has also been used as a hydroxamic acid hydroxyl isostere in a series of COX-2 and 5-LOX dual inhibitors, likely diminishing the metabolic toxicity expressed by some hydroxamic acids. While several methods exist for the fluorination and alkylfluorination of organic substrates, strategies for direct difluoromethylation are less common, particularly in the context of heteroarene substrates. In this Communication, the invention of a reagent to accomplish the mild, direct, scalable, and predictably selective difluoromethylation of heteroarenes and related structures is reported.

Currently, all known methods for heteroarene difluoromethylation rely on prefunctionalization through a programmed approach (Figure 1A). Perhaps the most widely known strategy involves difluorination of aldehydes using (diethylamino)sulfur trifluoride (DAST).^{9,10} Heteroarene-CF₂H compounds may also be accessed through a copper-catalyzed cross-coupling/ decarboxylation sequence, 11 or via radical debromination from a heteroarene-CF₂Br precursor. 12 Although these methods boast impressive levels of reactivity and site selectivity, the need for methods achieving the direct transfer of the CF₂H unit has been explicitly voiced in a recent review.¹³

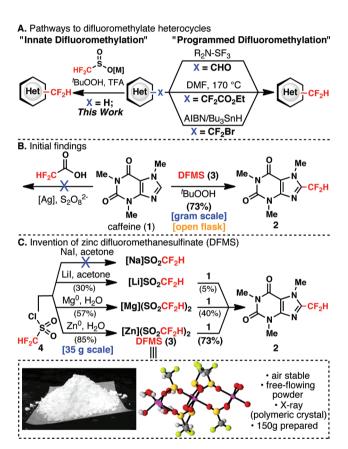


Figure 1. Invention of a new difluoromethylation reagent.

The pioneering work reported by Minisci on the decarboxylative generation of alkyl radicals and subsequent addition to heteroarenes (a form of innate 14 C-H functionalization) inspired initial forays into this area.¹⁵ Thus, difluoroacetic acid was the first CF₂H source that was tested on caffeine (1) under a variety of oxidative conditions (Figure 1B). However, this strategy was unsuccessful, necessitating the exploration of alternative methods for generating CF₂H radicals. The only previous example of direct radical transfer of a CF₂H unit was reported by Chen and coworkers in the context of additions to olefins and alkynes (no other substrate classes reported) using non-commercial and operationally problematic HCF₂I gas as a precursor. ¹⁶

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Table 1. Scope of C-H Difluoromethylation of Heteroarene Substrates

"Heterocycle (1.0 equiv), DFMS (2.0 equiv), tert-butyl hydroperoxide (3.0 equiv), TFA (1.0 equiv), 23 °C; isolated yields of chromatographically pure products are displayed, unless otherwise noted. Both indole and 1-(2,4-dimethylfuran-3-yl)ethanone were unreactive, giving recovered starting material. C2:C4:C6, 1.5:1.5:2. C2:C4:C6, 1:1:2. C2:C4:C6, 3:1:2. Reaction showed incomplete conversion after 12 h, and a second addition of DFMS (2.0 equiv) and tert-butyl hydroperoxide (3.0 equiv) was done. C4:C5, 4:1. Heterocycle (1.0 equiv), DFMS (3.0 equiv), tert-butyl hydroperoxide (4.0 equiv), 23 °C.

In contrast, we have previously demonstrated the ease and practicality associated with the use of stable fluoroalkyl metal sulfinate complexes for the generation of trifluoromethyl radicals and subsequent addition to heteroarenes.¹⁷ The seemingly simple extension of this approach to difluoromethylation was without precedent and required extensive experimentation. 18 Ultimately, after several strategies were evaluated, difluoromethanesulfonyl chloride was recognized as a convenient, commercially available starting point for the synthesis of a variety of different difluoromethylsulfinate reagents (Figure 1C). Using caffeine (1) as a model substrate, systematic variation of the metal counterion led to the identification of Zn(SO₂CF₂H)₂ (3, DFMS) as the optimum precursor for the CF₂H radical. DFMS is an easily prepared, air-stable, free-flowing white powder whose structure was confirmed by X-ray crystallographic analysis and shown to exist as a polymer in the solid state (see Supporting Information for more details).

With this new reagent in-hand, the scope of heteroarene difluoromethylation was evaluated on a broad cross-section of heterocyclic space. Many substrates showed good reactivity toward DFMS under the standard reaction conditions using tBuOOH in a CH₂Cl₂/H₂O solvent system, although select substrates suffered from poor conversion. In these cases, a second addition of DFMS and tBuOOH was added after 12–24 h to drive the reaction toward completion. It was also found that TFA showed improved rate and conversion for selected nitrogen heteroarene substrates, but was not essential to achieve the desired reactivity for most cases. Pyridines (5–10, 12, 22), pyrroles (14, 15), pyrimidines (18), quinoxalines (16), pyrazines (17), xanthines (2, 19, 20), purines (21), quinoline (23), thiadiazoles (13), and pyridinones (11) are all competent participants in the described method, which is tolerant of several potentially sensitive functional groups.

In most cases, substrates with multiple potential reaction sites exhibit high levels of regioselectivity, commonly producing only one observable regioisomer with C—H functionalization occurring at electron-deficient positions.¹⁷ It should be noted that all of the compounds illustrated in Table 1 are chemical entities with heretofore unreported synthetic procedures. In addition to the heteroarene substrates listed in Table 1, other organic substrates are also reactive toward difluoromethylation by the described process (Table 2). Aromatic thiols exhibit unexpected reactivity

Table 2. Difluoromethylation of Thiols and Enones^a

"Standard conditions were followed, and yields were obtained after silica gel chromatography. "DFMS (1.0 equiv) and tert-butyl hydroperoxide (1.5 equiv) were used. "Second addition of DFMS (2.0 equiv) and tert-butyl hydroperoxide (3.0 equiv). ${}^{d}\alpha_{,}\alpha_{,}\alpha_{-}$ Trifluorotoluene was used instead of dichloromethane. "Keto:enol, 1:5.

toward the CF₂H radical, leading to the generation of difluoromethyl thioethers. Radical difluoromethylation was also successful in the context of other electron-deficient π -systems such as $\alpha_i\beta$ -unsaturated enones.

Reactivity of fluoroalkyl radicals: •CF3 and •CF2H Electrophilic Nucleophilic Difluoromethylation **Trifluoromethylation DFMS HO** HO, **ΛOH** ^tBuOOH NaSO₂CF₃ MeO MeO MeC CH₂Cl₂/H₂O (44%)(49%)ref. 17 2 32 30 dihydroquinine **DFMS** CF₃ NaSO₂CF₃ ^tBuOOH CH₂Cl₂/H₂O (50%)C5:C2 4:1 (50%) ref. 17 33 varenicline (Chantix) 31

Figure 2. Regiochemical comparison of innate difluoro- and trifluoromethylations. Isolated yields after preparative HPLC purification.

In addition to the predictable site-selectivity observed in the difluoromethylation of simple small-molecule substrates, innate C-H difluoromethylation of complex reacting partners with many potential reactive sites is also predictable. As shown in Figure 2, the site-selectivity of difluoromethylation depends on the combined electronic properties of the reacting π -system and incoming radical species. This point is illustrated through a comparison between CF₃ and CF2H radical additions to dihydroquinine and varenicline (marketed in the U.S. as the prescription medication Chantix by Pfizer). In both cases, high levels of selectivity are observed for CF₃ and CF₂H radical addition, in spite of the multiple potentially reactive sites. For both dihydroquinine and varenicline, innate radical C-H trifluoromethylation takes place at the most electronrich position within the arene rings (C7 and C5, giving 32 and 33, respectively).¹⁷ Conversely, difluoromethylation occurs exclusively at electron-poor sites adjacent to heteroatoms within the heteroarene rings (both at C2, giving 30 and 31). The orthogonality of these two approaches is a powerful example of the ability to fine-tune an approach to alkylfluorination when considering the innate reactivity and electronic nature of the two reacting components.

Although many substrates listed in Table 1 produce a single observable regioisomer, it is possible to access alternative substitution in some cases by judicious choice of organic solvent media. As shown in Figure 3, 4-acetylpyridine shows exceptional regio-

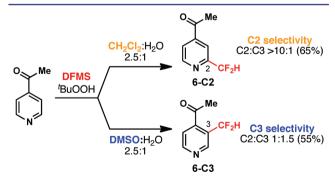


Figure 3. Solvent effects on regioselectivity. ^aStandard conditions were followed. ^bA second addition of DFMS (2.0 equiv) and *tert*-butyl hydroperoxide (3.0 equiv) was done.

selectivity in CH₂Cl₂/H₂O, leading to exclusive formation of the C2-CF₂H product (**6-C2**). However, substituting DMSO for CH₂Cl₂

leads to significant reversal of regiochemistry, favoring the C3- CF_2H isomer (6-C3) in 1.5:1.0 ratio. Although C3 selectivity is modest under these conditions, the change in selectivity is significant considering that the C3- CF_2H product is inaccessible under standard reaction conditions.

In summary, a new reagent (DFMS, 3) for direct difluoromethylation has been invented to access compounds of high value that, in almost all cases, were hitherto unknown. DFMS is effective for the direct transfer of a CF₂H unit to various organic substrates including heteroarenes, $\alpha_i\beta$ -unsaturated enones, and aromatic thiols via user-friendly, scalable, open-flask conditions. Ochanges in regioselectivity may be promoted by varying the organic cosolvent in the context of 4-substituted pyridines. Further examination of this and other mechanistic features is ongoing and will be reported in due course. DFMS has recently been commercialized by Sigma-Aldrich (product no. L510084).

ASSOCIATED CONTENT

S Supporting Information

Experimental procedures and analytical data for all new compounds, including ¹H, ¹³C, and ¹⁹F NMR and CIF files. This material is available free of charge via the Internet at http://pubs.acs.org.

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- (19) A sample of DFMS left open to air on the benchtop retained its original purity and reactivity after two months.
- (20) A provisional patent on this work has been filed, application no. 61565756.